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ISSUE CLASSIFICATION	
Class	Subclass

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E. SCANNED <i>SS</i> Q.A. <i>Am</i>	PATENT DATE
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APPLICATION NO. 09/756997	CONT/PRIOR F	CLASS 257 438	SUBCLASS 725	ART UNIT 28 1627	EXAMINER Novacek
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Caroline Boulenger

Method for eliminating development related defects in photoresist masks

PTO-204
12/89[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drawg.	Figs. Drawg.	Print Fig.	Total Claims
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